

Support Information

Ultra-long Distance Carrier Transportation in Bandgap-Graded

$\text{CdS}_x\text{Se}_{1-x}$ Nanowire Waveguides

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1. Experimental setup

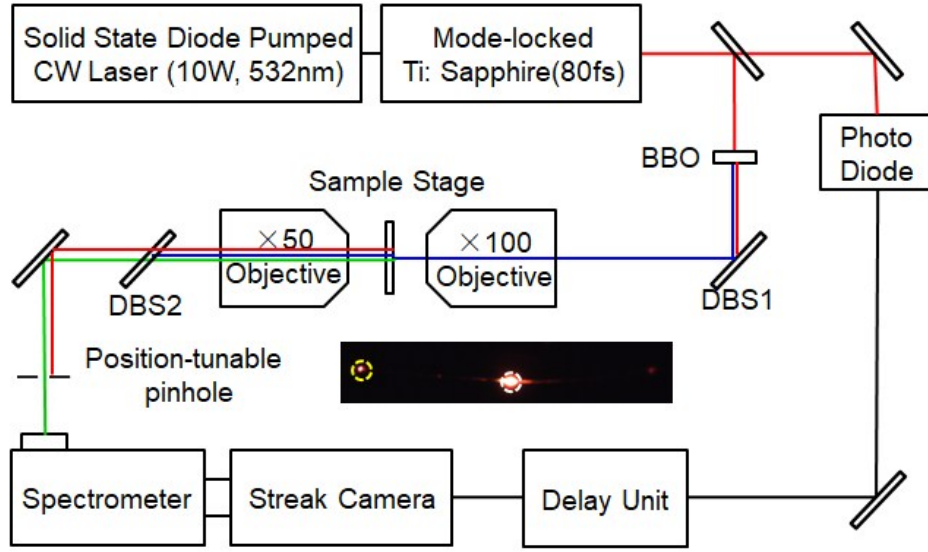


Fig. S1 Schematic diagram of the experimental setup. The PL signals originate from where other than selected area can be filtered by a position-tunable pinhole behind the microscope. Thus we can detect the PL signals only from waveguide. Inset : The real color PL image of the sample excited by a focused laser with a spot with $\sim 2 \mu\text{m}$.

The system used to detect the spatial and time resolved photoluminescence is a streak camera combined with a confocal microscope. A beam of the femto laser is focused to the sample through the confocal microscope to excite the sample and then the PL signals from selected area will be collected by another objective. After the objective, a position-tunable pin-hole has been placed in the middle of the light path from the objective to the spectrometer connected to the streak camera. This pin-hole is the key part to realize the spatial resolution. Because of the diffraction limit, the objective cannot just collect the PL signals only from selective area without the stray light from other area like the excited spot of the sample. Thus, this position-tunable pinhole is added and calibrated to screen those stray light from unselected area, so that only the PL signals from selected area will be induced into the streak camera.

2. Table S1. Fitted parameters for the in situ-TRPLs and SSTRPLs. Most of passive waveguide can be fitted well by the bi-exponential function. Only one passive PL curve of position 1 can be fitted by mono-exponential function.

The fitting parameters of the in situ-TRPLs and SSTRPLs

Parameters		P1 (1.93eV)	P2 (1.98eV)	P3 (2.03eV)	P4 (2.11eV)	P5 (2.21eV)
Passive waveguide	τ_1	-	119.6	116.4	101.5	-
	τ_2	809.45	756.3	712.9	364.2	-
	A_1	-	0.55	0.68	0.8	-
	A_2	1	0.45	0.32	0.2	-
Active waveguide	τ_1	-	125.8	97.1	78.4	109.3
	τ_2	-	387.8	365.1	375.6	478.7
	A_1	-	0.6	0.53	0.74	0.8
	A_2	-	0.4	0.47	0.26	0.2
<i>In situ</i> -TRPL	τ_1	150.2	133.8	149.4	74.3	38.2
	τ_2	1052	522.2	445.7	257.4	192.3
	A_1	0.66	0.72	0.79	0.83	0.91
	A_2	0.34	0.28	0.21	0.17	0.09

*Unit of time constants (τ_1 and τ_2): ps

3. The calculation of the photo-generated carrier density

The initial photo-generated carrier density in the CdS or CdSe nanowire can be calculated by the following equations:¹

$$N_{photo-generated\ carrier\ density} = \frac{j\sigma}{V} \quad (1)$$

$$\sigma = \frac{\omega}{n_l c} (\pi r^2 l) \left| \frac{4 \epsilon_l}{\epsilon_l + \epsilon_s} \right|^2 (2 n_s k_s) \quad (2)$$

In equation 1, j is the density of photons that goes to the surface of the nanowire in every single pulses, V is the volume of excited part of the nanowire, σ is the linear absorption cross section of the NW and can be calculated by equation 2, in which the ω is the angular frequency of the pump photon (400nm, $\sim 4.7 \times 10^{15} \text{ s}^{-1}$), n_l is refractive index of the surrounding medium (air, $n_l \sim 1.0$), and ϵ_l and ϵ_s are the dielectric constants of the surrounding medium and the nanowire (air, $\epsilon_l \sim 1.0$; CdS, $\epsilon_s = 6.18 + 1.70i$; CdSe, $\epsilon_s = 7.9 + 4i$).

In our work, the nanowire is excited by a beam of 400 nm pulsed laser with the frequency of 1kHz which focused into $\sim 500 \text{ nm}$, the diameter of the nanowire is about 600 nm and the power density of the laser is $64 \mu\text{J}/\text{cm}^2$. So we can estimate the the photo-generated carrier density of CdS nanowire and CdSe nanowire to be $1.18 \times 10^{16} \text{ cm}^{-3}$ and $1.37 \times 10^{16} \text{ cm}^{-3}$, respectively. With the sulfide/selenide ratios of different position on the composition graded NW taken into consideration, the photo-generated carrier density of the position from 1 to 5 on the Figure 1a can be estimated to be $1.24 \times 10^{16} \text{ cm}^{-3}$, $1.26 \times 10^{16} \text{ cm}^{-3}$, $1.28 \times 10^{16} \text{ cm}^{-3}$, $1.29 \times 10^{16} \text{ cm}^{-3}$, $1.31 \times 10^{16} \text{ cm}^{-3}$, respectively.

4. The PL spectra after active waveguide.

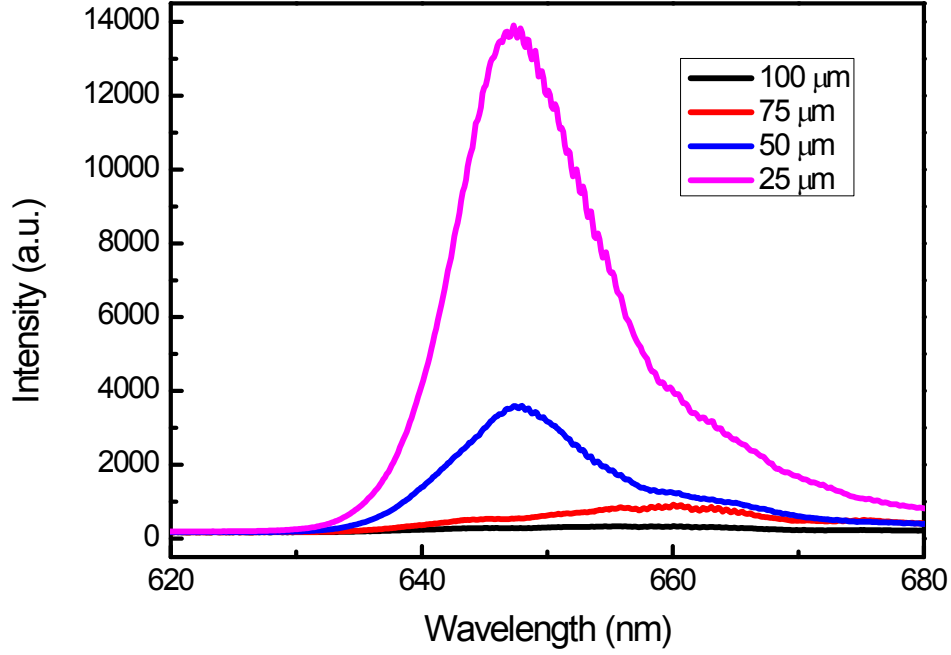


Fig. S2 The PL spectra after active waveguide in different distances. The strength of the PL decreases rapidly with the distance of the active waveguide getting longer.

5. The theoretical consumption of the light propagation through the composition-graded nanowires by the method of emitting-absorption-reemitting.

The consumption of the propagation of light through the sample can be calculated by the following equations.² The intensity of the PL signals propagated through the distance l can be calculated by:

$$I(l) = I_0 e^{-\alpha(h\nu)l} \quad (3)$$

where the I_0 is the initial intensity which is detected at the excited spot of the nanowire, l is the propagation distance and the $\alpha(h\nu)$ is the optical absorption coefficient which is dependent on the photon energy of light emit of the nanowire and because of the composition is continuous changing along the wire, the $\alpha(h\nu)$ is various too. The value of $\alpha(h\nu)$ can be calculated by:

$$\text{For } E \leq E_g(l), \quad \alpha(h\nu) = A_0 \sqrt{\frac{kT}{2\sigma}} \exp\left[\left(\frac{\sigma}{kT}\right)\left(E - E_g(l) - \frac{kT}{2\sigma}\right)\right] \quad (4)$$

$$\text{For } E > E_g(l), \quad \alpha(h\nu) = A_0 \sqrt{E - E_g(l)} \quad (5)$$

Among these two equations, the A_0 is the structure-related constant, kT is thermal energy at room temperature and σ is a composition-dependent dimensionless phenomenological fitting parameter. In our sample, the value of $\sigma(\text{WBG})$ and $\sigma(\text{NBG})$ is 2.3052 and 2.2106, respectively.

To simulate the method of emitting-absorption-remitting, we assume the composition-graded nanowire can be divided into n pieces of homogenous parts. In each part, the bandgap $E_g(i)$ and the $\sigma(i)$ can be calculated by the following two equations, respectively.

$$E_g(i) = E_g(0) + \frac{E_g(L) - E_g(0)}{n}i \quad (i = 0, 1, 2, \dots, n) \quad (6)$$

$$\sigma(i) = \sigma(0) + \frac{\sigma(L) - \sigma(0)}{n}i \quad (i = 0, 1, 2, \dots, n) \quad (7)$$

where the $E_g(0)$, $E_g(L)$, $\sigma(0)$, $\sigma(L)$ are the bandgap of the excited spot, the bandgap of propagation terminus, the σ of the excited spot and the σ of the propagation terminus, respectively.

Then, consider about the situation of emitting-absorption-remitting method, the intensity I_i at the propagation terminus can be calculated by:

$$I_i = I_{i-1} e^{-\alpha(h\nu)L/n} \quad (i = 1, 2, \dots, n) \quad (8)$$

In our work, the length of the nanowire, $L=100 \mu\text{m}$, $A_0=30000 \text{ cm}^{-1}\text{eV}^{-1/2}$, $kT=25 \text{ meV}$ and $n=100$.

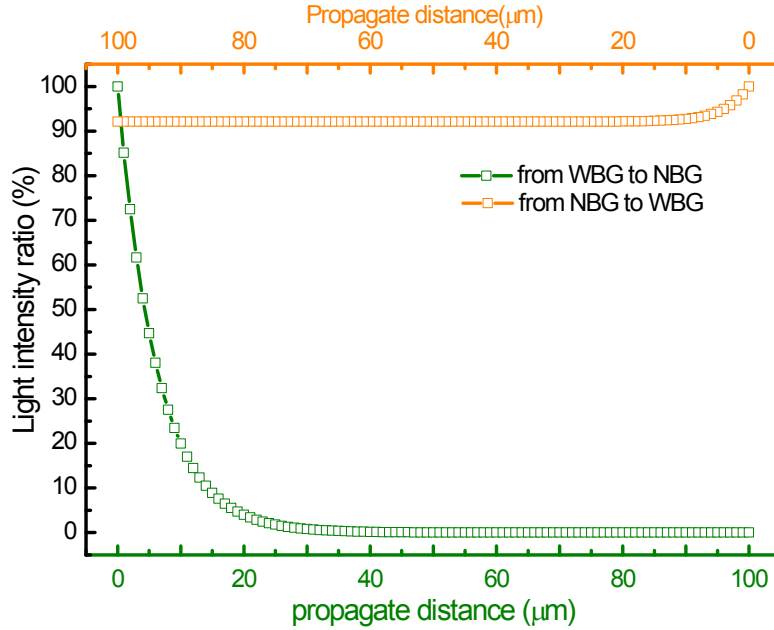


Fig. S3 The theoretical light intensity ratio trace of different propagation direction along the composition-graded nanowire.

With the bandgap of the excited spot and propagation terminus considered, the ratio of the intensity after the transport by the method of emitting-absorption-remitting was calculated and the plotted in the Fig. S2.

6. Quantum Yield Measurements.

Carboxylate-modified microspheres (Fluo Sphere, type F8816, $d=1\mu\text{m}$, $\lambda_{\text{em}}=645\text{ nm}$, Relative quantum yield QYR~18%) were supplied as a quantum yield reference in this experiment.³ To measure single microsphere emission, we diluted the microsphere solution and then dispersed it to a substrate to get monodisperse microsphere. A CW laser at 532 nm was used to excited single microsphere and the sample under laser power of ~50 nW. The emitted light was collected by an objective lens (Zeiss, $\times 100$, N.A.~0.9) and detected by a spectrometer (WITec, UHTS 300 SMFC). The integrated emission intensity counts IR (IS) for single microsphere (NW sample) were obtained. The quantum yield of a sample (QYs) can be calculated by using the following equation, $\text{QYs}=(\text{IS}/\text{IR})\times\text{QYR}$. The QY of the single NW is estimate to be around 0.5%-1% from $\text{CdS}_{0.75}\text{Se}_{0.25}$ to $\text{CdS}_{0.38}\text{Se}_{0.62}$.

Notes and references

1. I. Robel, B. A. Bunker, P. V. Kamat and M. Kuno, Nano Letters, 2006, 6, 1344-1349.
2. J. Xu, X. Zhuang, P. Guo, W. Huang, W. Hu, Q. Zhang, Q. Wan, X. Zhu, Z. Yang, L. Tong, X. Duan and A. Pan, Scientific Reports, 2012, 2.
3. F. Vietmeyer, P. A. Frantsuzov, B. Janko and M. Kuno, Physical Review B, 2011, 83, 10.